L Number	Hits	Search Text	DB	Time stamp
-	77203	lithography patterning	USPAT; US-PGPUB	2003/06/10 10:49
-	46889	beam with radiation) (flood with electron with beam	USPAT: US-PGPUB	2003/06/10 10:49
-	5073	(lithography patterning) and (beam with radiation) (flood with electron with beam)	USPAT; US-PGPUB	2003/06/09 14:09
-	2306	((lithography patterning) and (beam with radiation) (flood with electron with beam)) and (photoresist)	USPAT; US-PGPUB	2003/06/09 14:09
-	80	((((lithography patterning) and (beam with radiation) (flood with electron with beam)) and (photoresist)) and etching with polysilicon	USPAT; US-PGPUB	2003/06/10 10:51
-	25	5139904.URPN.	USPAT	2003/06/09 14:58
_	1	6183937.URPN.	USPAT	2003/06/09 14:59
-	7	("5139904" "5965461" "6107172" "6121155" "6153477" "6183937" "6232048").PN.	USPAT	2003/06/09 14:59
-	19	(((lithography patterning) and (beam with radiation) (flood with electron with beam)) and (photoresist)) and trim with etch\$3	USPAT; US-PGPUB	2003/06/09 15:29
-	14	("5264076" "5773199" "5837428" "5858621" "6080678" "6096659" "6136679" "6156629" "6218292" "6221776" "6297170" "6352922" "6365529" "6410421").PN.	USPAT	2003/06/09 15:50
_	23	5773199.URPN.	USPAT	2003/06/09 15:51
-	12	("Re30505" "3920483" "4253888" "5139904" "5308742" "5326727" "5368989" "5407787" "5656128" "5733714" "5753418" "5773199").PN.	USPAT	2003/06/09 15:52
_	14	("4625120" "4749436" "4868095" "4876177" "5096802" "5300403" "5385804" "5635333" "5641715" "5648198" "5650262" "5652084" "5660957" "5837428").PN.	USPAT	2003/06/09 16:02
-	6	(("6232048") or ("6197687") or ("6110837") or ("5876903") or ("5468595") or ("3997367")) PN.	USPAT; US-PGPUB	2003/06/10 10:48
-	4752	((430/328) or (438/671) or (438/723) or (430/313) or (430/296) or (438/371) or (438/719) or (438/720)).CCLS.	USPAT; US-PGPUB	2003/06/10 10:49
-	77388	lithography patterning	USPAT; US-PGPUB	2003/06/10 10:49
-	78540	beam with radiation) (flood with electron with beam	USPAT; US-PGPUB	2003/06/10 10:50
-	2659	(((430/328) or (438/671) or (438/723) or (430/313) or (430/296) or (438/371) or (438/719) or (438/720)). CCLS.) and (lithography patterning)	USPAT; US-PGPUB	2003/06/10 10:50
-	559	((((430/328) or (438/671) or (438/723) or (430/313) or (430/296) or (438/371) or (438/719) or (438/720)). CCLS.) and (lithography patterning)) and (beam with radiation) (flood with electron with beam)	USPAT; US-PGPUB	2003/06/10 10:50
-	80	((((lithography patterning) and (beam with radiation) (flood with electron with beam)) and (photoresist)) and etching with polysilicon	USPAT; US-PGPUB	2003/06/10 10:51
-	26	(((((430/328) or (438/671) or (438/723) or (430/313) or (430/296) or (438/371) or (438/719) or (438/720)). CCLS.) and (lithography patterning)) and (beam with radiation) (flood with electron with beam)) and ((((lithography patterning) and	USPAT; US-PGPUB	2003/06/10 10:51
		((((intrography patterning) and ((((intrography patterning) and (photoresist)) and etching with polysilicon)		